

## Index

- accurate mass measurement 115
- acetone, shake-up structure 75
- acid etching 5
- acid–base interaction 5, 184
- additive 2, 119, 149, 168
- adhesion 1, 6, 157, 174
- adhesive 1
- adiabatic approximation 61
- AES 21, 23, 97
- AFM 6, 8, 86, 175
- angle-resolved XPS 36, 85, 157, 179
- angular asymmetry factor 41, 42
- anode materials (*see* X-ray source)
- antimicrobial 3
- antioxidant 3, 4, 168
- antistatic agent 3, 4
- atom source 91
- attenuation length, electron 35, 36, 85
- Auger process 31, 33
- Auger series 7, 29, 32, 82
- autoadhesion (*see* heat sealability)
- automotive moulding, formulation of 3
  
- background
  - algorithms (XPS) 40
  - subtraction (XPS) 27, 40, 58
- band gap 32
- band structure calculation 82
- beam damage (*see* radiation damage)
- Beer–Lambert law 34
- benzene, shake-up structure 74
- Bethe equation 37
- binding energy
  - electron 7
  - referencing 47, 48
- biocompatibility 2, 6, 164
  
- biomedical polyurethane 162
- Biomer 167
- blocking 1
- blood bag 1
- Bragg equation 20
- bremsstrahlung radiation 17, 20, 21, 29, 49
  
- catalyst 2
- catheter 2
- cationisation 119
  - alkali ion 104, 147, 153
  - silver ion 104, 151, 176
- CCD camera 24
- cellulose 52
- cellulose trinitrate 52
- chain extender 163, 166
- channel electron multiplier (channeltron) 23, 95
- channel plate detector 24, 95
- charge
  - neutralisation 48, 53, 79, 97, 112
  - potential model 61
  - storage capacity 1
- chemical reactivity 1
- chemical shift (*see also* core level) 10, 53, 60, 156
  - carbon–halogen 62, 70
  - carbon–oxygen 64
  - carbon–nitrogen 64
- chemometrics 144
- chlorinated polypropylene 63
- cling 157
- cluster ion 101
- collision cascade 100
- colloidal polymer 142
- colourant 3
- composite 2
- compounding 2

- concentric hemispherical analyser (CHA) 21, 26  
conducting polymer 1, 184  
conduction band 32  
constant analyser energy (CAE) mode 23, 44  
constant retard ratio (CRR) mode 23  
contact angle 171  
contact lens 2  
contaminant 2, 4, 119, 144  
copolymer 2, 140, 144  
core level 10, 29, 52  
    width 30  
    lineshape 53, 60  
    vibrational fine structure 55  
corona discharge (*see* electrical discharge treatment)  
Coster–Kronig process 33  
coupling agent 3  
crazing 1  
critical surface tension 5  
cross-linking 2, 5, 144, 184  
crystallinity, degree of 2, 158  
curve-fitting 27, 58, 63, 67, 157  
cylindrical mirror analyser (CMA) 21
- datasystem 14, 27, 88, 97  
deconvolution 27, 58  
defluorination 5  
degradation index (*see* X-ray)  
depth distribution function 35  
depth profiling 11, 27, 85, 97, 179  
depth scale, surface properties 5  
derivatisation 83, 172  
detector XPS 23 SIMS 95  
deuterium exchange 146  
di-isononyl phthalate 150  
di-isopropylaminoethyl methacrylate 169  
di-octyl phthalate 148  
di-octyl sulphosuccinate 149  
differential charging 48  
dispersant 4  
domains, polymer blends 2, 164  
Doniach–Sunjic theory 53  
doping (*see* conducting polymer)  
double anode (*see* X-ray source)  
drug release vehicle 1  
dynamic SIMS 11, 101, 102
- E–X* imaging 26, 181  
EELS 8  
elastic electron scattering 35, 86  
electrical discharge treatment 5, 170  
electrical properties, polymers 1  
electroactive polymer (*see* conducting polymer)  
electron energy analyser 14, 21  
electron flood gun 47, 112  
electron retardation 23  
electron scattering 34  
electron stimulated desorption (ESD) 112, 114  
electron stimulated ion emission (ESIE) 112, 114  
electronic sputtering 102  
element, detection of XPS 30, 156 SIMS 119, 156  
ellipsometry 8, 36  
EMA polymers, surface structure 157
- end-groups, polymer 2, 142, 146, 152, 165  
energy compensation, ToFSIMS 94  
energy filter, SIMS 92, 112  
energy resolution 10, 53, 58  
    absolute 21  
    relative 21  
    resolving power 21  
epoxy resin 1  
equivalent cores approximation 58  
erucamide 148  
ESCA 10  
escape depth, electrons 36, 48  
etendue, electron spectrometer 41, 43  
ethylene bis-stearamide 148  
extra-atomic relaxation 62
- factor analysis 27  
Fermi level 31, 32, 48  
fibre 1, 4  
filler 3, 4  
film 1, 4, 157, 170  
final state effect, XPS 61, 69  
final state configuration interaction calculation 75  
finish, fibre 4  
flame retardant 3  
flame treatment 5  
foaming agent 3  
fragmentation, SSIMS (*see* secondary ion formation)  
Franck–Condon principle 55, 58  
friction 1, 6  
functional group labelling (*see* derivatisation)  
functionalisation, polymer 5
- Gauss–Lorentzian ratio 53, 55, 60  
GIXRD 8  
gloss 1  
glyceryl monostearate 148  
grease 1
- H-bonding 5, 171  
hard segment (*see* poly(urethane))  
haze 1  
He scattering 8  
heat sealability 1, 5, 157, 171  
heat stabiliser 3, 4  
hexatriacontane 49, 55  
high mass resolution 94, 117, 119, 129, 160, 175  
hydraulic fluid 1  
hydrocarbon contamination 45, 49  
hydrocarbon polymers 55, 65, 78, 121
- imaging in  
    SIMS 12, 96, 111, 179  
    XPS 24, 181  
inductive effect 63  
inelastic mean free path, electron 35, 36, 41  
inelastic scattering, electron 34, 74  
infrared spectroscopy 7, 8, 167, 171  
initial state effect, XPS 61, 69  
instrumentation 16, 88, 156  
intra-atomic relaxation 61  
ion scattering spectroscopy 8

- ion source 89
  - Cs 90
  - electron impact 89, 91
  - Ga 91
  - In 91
  - liquid metal 90, 96, 112
    - noble gas (Ar, Xe) 89, 91
  - pulsed 89, 90
  - surface ionisation 90
- ionisation, SSIMS 102
- Irgafos 168
- Irganox 1010 149
- Irganox 245 168
- isotope, detection of 11, 120, 138, 146
- kinetic energy,
  - Auger electron 33
  - photoelectron 7, 10
  - secondary ion 92, 93
- lamination 170
- Langmuir–Blodgett film 36
- lateral resolution (*see* spatial resolution)
- latex polymer 142
- LEED 8
- liquid crystal display 1
- lubricant 3, 4
- lubricity 1
- Madelung potential 61
- mass calibration, ToFSIMS 115
- mass resolution
  - quadrupole mass spectrometer 92
  - ToF mass spectrometer 94, 119
- matrix effect 102, 149
- methane, vibrational fine structure 55
- microanalysis 11, 27, 96, 183
- microchannel plate (*see* channel plate)
- microprobe, imaging approach
  - SSIMS 96, 100
  - XPS 25
- migration, additives 4, 84
- molecular orbital calculation 81, 82, 189
- molecular weight distribution 2, 144, 152
- monochromator (*see* X-ray monochromation)
- mould release agent 3
- moulding 1, 3
- mu-metal 14
- multidetector, XPS 24
- neutron reflectometry 8, 179
- NEXAFS 8
- nomenclature
  - Auger series 33
  - core level 29
- nonyl phenol ethoxylate 148
- nylon-6 81, 135
- odd-electron ions 147
- offsetting, from film 4
- oleamide 148
- oligomer 2, 98, 152
- optical fibre coating 1
- optical properties, polymer 1
- organic mass spectrometry 11, 104, 116
  - chemical ionisation 104, 147
  - electron impact 104, 147
  - field desorption 104
- oxidation, polymer 5, 157, 171
- packaging 5
- paint 1
- palmitic acid 148
- pass energy, electron energy analyser 23
- perfluoropolyether 142
- permeability 1
- peroxide 3
- photoelectric effect 7, 27
- photoemission
  - cross-section 30, 41, 45, 52
  - elastic 29, 34
  - inelastic 29, 34
  - process 27
- pigment 3, 4
- plasma deposition 5, 36
- plasma desorption mass spectrometry 102
- plasma treatment 5, 146
- plasticiser 3, 4
- polarisation relaxation 53
- poly(2-ethyl oxazoline) 46
- poly(4-bromostyrene) 46
- poly(4-methyl-pentene-1) 122
- poly(acetylacetoxyethyl methacrylate) 67
- poly(acetylene) 184, 186
- poly(acrylate) 123
- poly(acrylamide) 52
- poly(acrylonitrile) 54
- poly(allylamine) 46
- poly(allylamine hydrochloride) 46
- poly(amide) 135
- poly(aniline) 184, 186
- poly(but-1-ene) 78, 122
- poly(caprolactam) (*see* nylon-6)
- poly(caprolactone) 72
- poly(carbonate) 135, 142
- poly(chloroethyl methacrylate) 51, 52
- poly(chlorostyrene) 51, 78
- poly(cis-butadiene) 52
- poly(dimethyl siloxane) (silicone) 13, 46, 52, 86, 117, 138, 148
- poly(ester) 1, 132
- poly(ether) 132, 163
- poly(ether ether ketone) 52, 66
- poly(ethyl acrylate) 52
- poly(ethyl acrylate) 132
- poly(ethyl methacrylate-co-hydroxyethyl methacrylate) 140
- poly(ethylene) 5, 48, 55, 78, 122, 170
- poly(ethylene glycol) 52, 132, 142, 146, 148, 153
- poly(ethylene sulphide) 46, 49
- poly(ethylene terephthalate) (PET) 13, 55, 58, 98, 107, 112, 132
- poly(ethylene-co-chlorotrifluoroethylene) 46, 48
- poly(ethylene-co-methylacrylate) 157
- poly(imide) 66, 78
- poly(isobutylene) 121, 122

- poly(isoprene) 66  
 poly(ketone) 78  
 poly(lauryl methacrylate) 55  
 poly(methacrylate) 123  
 poly(methacrylonitrile) 46  
 poly(methyl acrylate) 59, 72  
 poly(methyl methacrylate) (PMMA) 36, 38, 39, 52, 75, 109, 110, 125, 128, 130, 142  
 poly(methyl methacrylate-co-PEG methacrylate) 153  
 poly(n-butyl methacrylate) 142  
 poly(phenylene) 184  
 poly(phenylene sulphide) 184  
 poly(phenylene vinylene) 184  
 poly(phosphazene) 28, 70  
 poly(propylene) 3, 52, 55, 78, 121, 122, 170, 174  
 poly(propylene glycol) 46, 148, 164  
 poly(pyrole) 184  
 poly(siloxane) 58  
 poly(styrene) 12, 52, 55, 65, 74, 119, 121, 123, 125, 146, 150  
 poly(sulphone) 78  
 poly(tetrafluoroethylene) (PTFE) 5, 10, 13, 46, 48, 52, 138  
 poly(thiophene) 184, 187  
 poly(trifluoroethyl acrylate) 82  
 poly(urethane) 72, 117, 135, 140, 162  
 poly(vinyl acetate) 59, 72  
 poly(vinyl carboxylate) 123  
 poly(vinyl chloride) (PVC) 46, 49, 51, 52, 117, 138  
 poly(vinyl ether) 123  
 poly(vinyl ethyl ether) 126, 127  
 poly(vinyl ethyl ketone) 126, 127  
 poly(vinyl ketone) 123  
 poly(vinyl methyl ether) 46  
 poly(vinyl methyl ketone) 75, 78, 83  
 poly(vinyl propionate) 126, 127  
 poly(vinylidene chloride) 51  
 poly(vinylidene fluoride) 138  
 polycyclic aromatic ions 121, 124  
 polymer fragment ions 123
  - halogen-containing 138
  - main-chain-oxygen-containing 132
  - nitrogen-containing 135
  - side-chain oxygen functions 123
  - silicones 138
 polymerisation 4  
 Poschenreider mass analyser 94  
 position sensitive detector 24, 26, 97  
 primary substituent effect, chemical shift 62  
 printability 1, 157, 170, 174  
 printing ink 1, 5, 174  
 processing, polymer 2, 4  
 prompt collisional sputtering 100  
 pump oil 4
- quadrupole mass analyser 11, 89, 91, 106  
 quantification
  - SSIMS 139, 160, 165
  - XPS 27, 39, 78, 157, 166, 173
  - XPS/SSIMS correlation 139, 162
 quartz crystal monochromator 20
- radiation damage in
  - SSIMS 11, 91, 108, 147
  - XPS 47, 49, 53, 79
 Raman spectroscopy 8  
 RBS 8  
 reflectron mass analyser 94  
 relative atomic sensitivity factor 44, 46  
 relaxation effect, core level 55, 58, 63, 69, 73  
 relaxation energy 61  
 release agent 4, 13  
 releaseability 1  
 repellency agent 3  
 retrospective image analysis, SSIMS 96, 181  
 rotating anode 21  
 Rowland circle 20  
 rubber 51  
 rubber modifier 4
- sample charging (*see also* charge neutralisation)
  - XPS 47
  - SSIMS 112
 sample cooling 17, 147  
 sample damage (*see* radiation damage)  
 sample handling 16  
 sampling depth
  - SSIMS 116, 156, 180
  - XPS 34, 39, 87, 156
 scanning probe microscopy 6  
 secondary ion
  - attenuation 117
  - energy distribution 108, 113, 116
  - formation 100, 104, 108
  - fragmentation 102, 152
  - from polymers 104
  - from surface molecules 146
  - yield 93
 secondary substituent effect, chemical shift 93  
 self-assembled monolayer 6  
 selvedge 103, 147  
 SEM 180  
 shake-off 61, 73  
 shake-up 58, 62, 72, 73  
 Shirley background 40, 45  
 signal: noise, XPS 21, 53, 85  
 silicone (*see* poly(dimethyl siloxane))  
 sodium dodecyl sulphate 149  
 sodium naphthalenide 5  
 soft segment (*see* poly(urethane))  
 solvent wipe 5  
 solvent, retained 184  
 spatial resolution 6, 11, 25, 96, 156  
 spherical sector analyser (*see* CHA)  
 spherulite 2  
 spin-orbit splitting 30, 73  
 sputtering 11, 85, 100
  - simulation 101
 SSIMS
  - definition 108
  - history 11
  - instrumentation 88
  - physical basis 100
  - threshold 109

- static SIMS conditions 12, 108
- stearamide 148
- stearic acid 148
- stigmatic imaging 90, 96
- STM 8
- sudden approximation 61, 73
- surface
  - analysis techniques 6
  - behaviour 5
  - contamination 15
  - difference from bulk 2
  - engineering 5
  - grafting 5
  - modification 4
  - pretreatment 4, 170
  - roughness 6, 41, 86
  - segregation 4, 117, 140, 165, 179
- take-off angle, XPS 27, 36, 39, 47, 85, 116
- tandem mass spectrometry 106
- Taylor cone 90
- TEM 2
- thermal sputtering 101
- thermoplastic 2
- thermoset 1, 2
- ToF mass analyser 12, 89, 93
- Tougaard background 40, 45
- transfer lens, XPS 14, 22
- transmission (efficiency)
  - electron spectrometer 44
  - quadrupole mass spectrometer 92
  - ToF mass spectrometer 94
- triboelectric behaviour 1
- TRIFT mass analyser 94, 108
- triphenyl phosphate 148
- UHV 6, 10, 11, 15, 49
- universal curve 37
- useful ion yield 111
- UV stabiliser 3, 4
- vacuum pumps 16
- vacuum system 14, 88
- valence band 17, 29, 31, 78, 189
- vibrational excitation 55
- Viton A 73
- weak boundary layer 174
- wear 1
- wetability 1, 5, 157
- wetting 6
- Wien (mass) filter 89
- work function 7, 29
- X-alpha calculation 82
- XPS
  - equation 7, 29
  - history 7
  - instrumentation 14
  - intensity 41
  - spectrum 27
  - surface sensitivity 8, 34
- X-ray
  - ghost 19, 20
  - satellite 17, 20, 79
- X-ray degradation index 51
- X-ray emission spectrum 17
- X-ray fluorescence 31, 32
- X-ray focussing 21, 48
- X-ray monochromation 20, 24, 55
- X-ray reflectometry 8
- X-ray source 4, 17
- X-ray spectroscopy 7